

**PATENT APPLICATION**  
**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q76587

Kouji TAKAHASHI, et al.

Appln. No.: 10/619,181

Group Art Unit: 1731

Confirmation No.: 4972

Examiner: Ms. Anna L. Kinney

Filed: July 15, 2003

For: GLASS SUBSTRATE FOR A MASK BLANK, METHOD OF PRODUCING A GLASS SUBSTRATE FOR A MASK BLANK, MASK BLANK, METHOD OF PRODUCING THE MASK BLANK, TRANSFER MASK, AND METHOD OF PRODUCING A TRANSFER MASK

**RESPONSE TO RESTRICTION REQUIREMENT**

**MAIL STOP AMENDMENT**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated April 25, 2006, please consider the remarks as submitted herewith on the accompanying pages.

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